Search Notes

Application/Control No.	Applicant(s)/Patent under Reexamination
10/701,402	WONG ET AL.
Examiner	Art Unit

Rebecca M. Stadler

1754

SEARCHED					
Class	Subclass	Date	Examiner		
423	447.2	4/24/2006	RMS		
423	415.1	4/24/2006	RMS		
423	460	4/24/2006	RMS		
977	745	4/24/2006	RMS		
977	748	4/24/2006	RMS		
977	847	4/24/2006	RMS		
423	447.1	4/24/2006	RMS		

INTERFERENCE SEARCHED					
Class	Subclass	Date	Examiner		
423	447.2	4/24/2006	RMS		
All	above	4/24/2006	RMS		

SEARCH NO (INCLUDING SEARCH		)
	DATE	EXMR
STN search - carbon nano? and ozon?; fullerene and ozon?	4/24/2006	RMS
Inventor Name Search	4/24/2006	RMS
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